

Progress towards laser plasma acceleration based free electron laser on COXINEL

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Introduction



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Towards laser plasma acceleration based Free Electron Lasers

Motivation : Exploit the present laser plasma acceleration performance for undulator radiation and a Free Electron Laser applications

LPA versus conventional accelerator



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Introduction



Planar undulator



Undulator radiation





Single electron emission : homogeneous linewidth interference from trains of N_u periods :

Intensity $\alpha N_{u^{2}}$ $\left(\frac{\Delta\lambda}{\lambda_{n}}\right)_{hom} \approx \frac{1}{nN_{u}}$ $\mathscr{B}_{ph} \propto \frac{\Delta\lambda}{\lambda_{n}}$

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Multi-electron emission : Inhomogeneous linewidth
energy spreaddivergence and size (emittance)

When $(\Delta\lambda/\lambda)_{inh}$ becomes dominant, Intensity α N_u

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Introduction



Free Electron Laser

SASE (Self Amplified Spontaneous Emission)



R. Bonifacio et al, Opt. Comm. 50, 1984, 376, K. J. Kim et al, PRL57, 1986, 1871, C. Pelligrini et al, NIMA475, 2001, 1, A.M. Kondratenko et al, Sou Phys. Dokl. 24 (12), 1979, 989



- good transverse coherence spike
- single spike (low charge, chrip/taper), self-seeding



S. Reiche et al., NIMA 593 (2008) 45-48 L. Giannessi et al., Phys. Rev. Lett. 106, 144801 (2011)

Seeding: one laser-electron interaction



• temporal coherence given by the external seed laser

• improved stability (intensity, spectral fluctuations and jitter)

- quicker saturation
- good transverse coherence
- Seed : laser and HHG (160, 60, 30 nm)
- up-frequency multiplication (260 nm -> 4 nm at FERMI)

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L. H.Yu et al, PRL912003, 074801 L. H.Yu et al, Science 289, 2000, 932 T. Saftan APAC 2004, Gyeongu

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Introduction



Undulator radiation and FEL requirements

In transverse (transverse sizes and divergences)

Undulator

FEL

$$\left(\frac{\Delta\lambda}{\lambda_n}\right)_{\sigma'}^{\checkmark} \left(\frac{\Delta\lambda}{\lambda_n}\right)_{hot}$$

 $\frac{\mathcal{E}_n}{\gamma} < \frac{\lambda}{4\pi}$

In longitudinal (energy spread and bunch length)



=> Handling of the divergence

• Plasma lens (passive, active)

R. Lehe et al. PRSTAB. 17, 121301 (2014) C.Thaury et al. Nature Comm. 6, 6860 (2015) J.Van Tilborg et al., PRL 115, 184802 (2015) Nakanii N. et al., PRASTAB 18, 021303 (2015) T. Hosokai et al, PRL 97, 075004 (2006) T. Hosokai et al. "APL 96, 121501 (2010) S. Steinke et al., Nature (2016) R. Pompili Applied Physics Letters, 110(10), 104101.

• High gradient quadrupole (permanent magnet based)

A. Ghaith et al., Instruments 2019, 3, 27; doi:10.3390/ instruments3020027 (2019) M. P. Anania et al., Appl. Phys. Lett. 104, 264102 (2014) F. Marteau et al., Appl. Phys. Lett. 111, 253503 (2017)

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=> Handling of the energy spread

• Demixing chicane

A. R. Maier et al., Phys. Rev. X 2, 031019 (2012) M. E. Couprie et al. J. Physics B :At., Mol. Opt. Phys. (2014) 234001 P.Antici et al., J. Appl. Phys. 112, 044902 (2012) M. Migliorati et al. Phys. Rev. Spec. Topics AB 16, 011302 (2013)



Energy de-mixing Chicane



• Tranverse gradient undulator



N. M. Kroll et al. Quantum Electronics, IEEE , 17(8), 1496-1507 (1981) T. Smith, J. M. J. Madey, L. R. Elias, and D. A. G. Deacon, J. Appl. Phys. 50, 4580 (1979) Z. Huang et al., Phys. Rev. Lett. 109, 204801 (2012)

B_u(x)=B_{u,0}(1+αx), α the gradient coefficient dispersive optics => x= $\eta \Delta \gamma / \gamma$, resonant condition fulfilled for $\eta = (2 + Ko^2)/\alpha Ko^2$.

canted magnetic poles

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COXINEL : a test experiment towards a LWFA FEL amplification

I- COXINEL set-up and modelling

The laser and electron source

Responsability Laboratoire d'Optique Appliquée (LOA), S. Corde, C. Thaury

Laser $2 \times 60 \text{ TW}$ of LOA, used for 3 different fields

Laser Characteristics: Ti:Sa (800 nm) Pulse Duration = 30 fs Energy = 1.2-1.5 J on target

Ionization injection 99% He, I % N₂ Robustness High charge

Laser upgrade : I 20 TW, 25 fs, 2.75-3.5 J on target for the main pulse

II- COXINEL components

Valorisation

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Permanent magnet quadrupole with variable gradient for the LPA beam divergence handling

Gradient : up to 200 T/m Variability by 50 % Integrated gradient : 10 T Bore diameter : 10 mm

QUAPEVA 1: +102.8 T/m , QUAPEVA 2: -101.2 T/m, QUAPEVA 3: +88.17 T/m

Patent :

- « Multi-pôle magnétique réglable », C. Benabderrahmane, M. E. Couprie, SOLEIL, F. Forest, O. Cosson Sigmaphi, Numéro de dépôt : 1458335

Adjustable magnetic multipole, 5/09/2014- WO 2016034490 A1, publication : 10 mars 2016 - Europe : PCT/EP2015/069649 of 27/08/2015

F. Marteau et al., Variable high gradient permanent magnet quadrupole (QUAPEVA), Appl. Phys. Lett. 111, 253503 (2017) A. Ghaith et al., Tunable High Gradient Quadrupoles For A Laser Plasma Acceleration Based FEL, Nuclear Inst. and Methods in Physics Research, A 909 (2018) 290–293

A. Ghaith et al. Permanent Magnet Based Quadrupoles, Submitted to Intruments, MDPI, (2019)

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The undulator

UI8 n°2 undulator (cryo-ready, used at room temperature)

UI8 n2 : 2 m cryo-ready hybrid PrFeB UI8 undulator I8 mm period

Remanent field :1.35 (1.57)T @ 300 (77) K Hcj : 1.63 (7.6) T @ 300 (77) K Minimum gap : 5.5 mm B= 1.15 T at 77 K, K = 1.93

Valléau, M., Benabderrahmane, C., Briquez, F., Berteaud, P., Tavakoli, K., Zerbib, D., ... & Vétéran, J. (2016, July). Development of cryogenic undulators with PrFeB magnets at SOLEIL. In AIP Conference Proceedings (Vol. 1741, No. 1, p. 020024). AIP Publishing. M.Valléau, et al., Development of Cryogenic Undulators with PrFeB magnets at SOLEIL, Journal of Physics : Conferences Series (proceedings of SRI 2015)

M.Valléau

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II- COXINEL components

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The COXINEL components

M. E. Couprie, Plasma Physics and Controlled Fusion, Volume 58, Number 3 (2016), M. Labat et al. J. Synchrotron Rad. (2018). 25, 68-71 https://doi.org/10.110 S1600577517015284, M. Labat et al., "Electron and photon diagnostics for plasma acceleration-based FELs." Journal of synchrotron radiation 25.1 (2018).

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II- COXINEL components

The COXINEL line

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Electron beam

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III- COXINEL electron beam transport

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III- COXINEL electron beam transport

Adjustment of the vertical dispersion in the chicane

Beam Pointing Alignment Compensation

Matrix response method :

S [m]

T.André et al., Control of laser plasma accelerated electrons for light sources, Nature Communications (2018) 9:1334

III- COXINEL electron beam transport

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Adjustment of the focused electron beam energy

T. André et al., Control of laser plasma accelerated electrons for light sources, Nature Communications (2018) 9:1334, T. André PhD 2018

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COXINEL : proper transport along the line

T. André et al., Control of laser plasma accelerated electrons for light sources, Nature Communications (2018) 9:1334, T. André PhD 2018 D. Oumbarek_Espinos et al., Skew quadrupole effect of laser plasma electron beam transport, Applied Science, 9(12), 2447 (2019).

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VI- COXINEL undulator radiation

Transverse pattern measured with a CCD camera Undulator set to radiate at 200 nm for 176 MeV $\lambda_{\rm n} = \frac{\lambda_{\rm u}}{2n\gamma^2} \left(1 + \frac{K_{\rm u}^2}{2} + \gamma^2 \theta^2 \right)$ 4 mm slit : 17.4 -> 5.2 pC Wavelength (nm) 000 000 000 Flux (10⁵ counts/mm²) b a 0.5 1 1.5 300 nm 10 254 nm 200 nm (mm) 7 11:27:29 2017 0 $K_u \propto \exp\left(-ag/\lambda_u + bg^2/\lambda_u^2\right)$ e -10 10 -10 10 0 -10 0 Normalized counts (10⁵/pC) $P \propto K_u^2$ without slit ized a bit the position wit OAF (and the streen X (mm) С with slit, 300 nm BP filter Charge density (a.u.) 0 1.0 1.0 1.0 1.0 Initial e distribution with slit, 250 nm BP filter 0.6 with slit, 200 nm BP filter without slit 30 % ÷20 0.2 8 % 10 6 14 200 100 150 250 Undulator gap (mm) Energy (MeV) Ч N_{ph} ~ 3 10⁷ ph/pC T.Ardré et al., Control of laser plasmanaccelerated electrons for light sources, Nature Communications (2018) 9:1334 254 nm la d'Elba, Italy, 15-21 septembre 2019 erc 200 nm -

Conclusion

 Electron beam transport over 9 m enabling beam manipulation with a broadband energy beam:
Beam pointing alignment compensation method

Fine tuning of the electron beam energy Limited emittance growth at the undulator location

• Undulator spontaneous emission measured after transport beam manipulation:

